

<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  <i>(use as many sheets as necessary)</i>		<b>Complete If Known</b>	
		Application Number	10/749,336
		Filing Date	
		First Named Inventor	Li Wang
		Art Unit	
		Examiner Name	
Attorney Docket Number	107326		

**U.S. PATENT DOCUMENTS**

EXAMINER INITIALS	DOCUMENT NUMBER	PUB. DATE	NAME OF PATENTEE OR APPLICANT OF CITED DOCUMENT	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
TN	US 3,923,641	12-1975	Morrison	208	111	02-20-1974
	US 4,612,108	09-1986	Angevine et al.	208	111	08-05-1985
	US 4,757,041	07-1988	Oleck et al.	502	65	12-16-1986
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	US 4,983,273	01-1991	Kennedy et al.	208	89	10-05-1989
	US 5,128,024	07-1992	LaPierre et al.	208	89	03-25-1991
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	US 5,284,573	02-1994	LaPierre et al.	208	89	07-02-1991
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**FOREIGN PATENT DOCUMENTS**

	DOCUMENT NUMBER	PUB. DATE MM-YYYY	COUNTRY	CLASS	SUBCLASS	TRANSLATION _____	YES	NO
TN	EP O 955 093 A1	10.11.1999	EPO	B01J	29/48			X
TN	Appln 11-156198	06-1999	Japan				X	

**OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)**

TN		DATABASE WPI Section Ch, Week 200001 Derwent Publications Ltd., London, GB; Class H06, AN 1999-348058 XP002237545 & JP 11 156198 A (China Petrochemical Corp), 15 June 1999 (1999-06-15) abstract		
		EXAMINER	DATE CONSIDERED	6/7/06

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.